Ex ante life cycle assessment of GaAs/Si nanowire–based tandem solar cells: a benchmark for industrialization

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Abstract

Purpose The goal of this study is to perform an ex-ante life cycle assessment (LCA) of the emerging gallium-arsenide nanowire tandem solar cells on silicon (GaAs/Si) and to provide a benchmark for the commercialization of the technology. The environmental impacts and energy payback time (EPBT) of the GaAs/Si modules are compared with those of the incumbent single-Si modules. Parameters and efficiencies most relevant to be optimized in order to commercialize the technology are identified and discussed.

Methods Two production routes for GaAs/Si solar cells are being up-scaled: the growth of GaAs nanowires on a native substrate, peel-off, and transfer to a silicon substrate (transfer route) and the direct growth of GaAs nanowires on a silicon substrate with assistance of a silicon-dioxide (SiO₂) nanotube template (direct growth route). Two ex-ante LCAs for the different manufacturing routes and an LCA for the incumbent single-Si technology were conducted. Environmental impacts of the GaAs/Si technology were assessed and compared with the incumbent. Various scenarios regarding sensitive parameters and processes were modeled—such as modeling several industrial scale tools, the energy consumption of sensitive processes, the number of substrate reuses, the frequency of re-polishing the wafer, and benchmarking the scale of improvement of major impact drivers.

Results and discussion The analysis showed that, if expected process efficiencies are achieved, a 28% efficient GaAs/Si module performs 5 to 20% better (transfer route) and 20 to 30% better (direct growth route, except the ozone depletion impact) compared with an 18% efficient single-Si module, for all impact categories assessed—climate change, land use, acidification, ozone depletion, freshwater, marine, terrestrial ecotoxicity, eutrophication, human toxicity, and photochemical oxidation. Critical hotspots identified include the use of gold, trifluoromethane (CHF₃), and a GaAs wafer. The EPBT of the GaAs/Si nanowire tandem module is in between 1.37 (expected process efficiencies achieved) and 1.9 years (worst case scenario), while the EPBT of the single-Si module is 1.84 years. Results can be considered as a benchmark for the successful commercialization of the technology.

Conclusions If 28% efficient GaAs/Si nanowire tandem modules are developed, expected process efficiencies are achieved, and at least 100 reuses of the GaAs substrate (transfer route) are realized; then, the GaAs/Si modules perform better compared with an 18% efficient single-Si module for most impact categories assessed. Conclusions from the ex-ante LCA are conditional (if-then) and can be used as a benchmark, allowing to quantify the efficiencies that need to be achieved to commercialize the technology.

Keywords Ex-ante · Prospective · Life cycle assessment · Emerging technologies · Benchmark · Photovoltaics · Nanomaterials · Solar cells

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1 Introduction

Solar energy is expected to play a significant role in climate change mitigation (Rogelj et al. 2018). Photovoltaic (PV) installation has grown from 13.4 GW of cumulative installed PV capacity in 2008 to more than 400 GW at the end of 2017, and is expected to grow beyond 3000 GW by 2040 (IEA - PVPS 2009, 2017; ITRPV 2018; IEA - World Energy Outlook 2019). The current dominant PV technologies, with more than 90% of the global installed PV capacity (IEA 2017), are the crystalline-silicon (Si) technologies. These crystalline-Si PVs

are, however, bounded to a theoretical conversion efficiency limit of 29.4% (Richter et al. 2013).

In order to overcome the efficiency limitation of current commercial photovoltaics, novel solar technologies are required. One example of such an innovation is the use of nanomaterials, for instance nanowires (NWs), in solar PVs (Otnes and Borgström 2017; Borgström et al. 2018). A combination of commercial crystalline-Si solar cells and III–V materials—materials with good semiconductor properties—can result in solar cells with higher conversion efficiency. The higher efficiency is achieved by combining different materials that can convert different parts of the light spectrum into electricity, resulting in a more efficient solar cell (Wallentin et al. 2013). In this study, we consider a gallium-arsenide (GaAs) nanowire solar cell on top of a crystalline silicon substrate. This is a two-junction solar cell (so-called tandem cell), in which the bottom junction consists of a single-Si solar cell and the top junction consists of a layer of nanowires. The current world highest efficiency of a III–V tandem solar cell on Si is 32.8% (Green et al. 2018) with the potential to reach efficiencies beyond 40% (Almansouri et al. 2015; Essig et al. 2017).

One main disadvantage of the III–V multijunction solar cells is the high production cost (Essig et al. 2017) which until now has limited the use of such solar technologies in area-restricted and critical applications like space technologies (Chiu et al. 2014). Another concern is that, although the use of nanomaterials in solar cells has the potential to produce photovoltaic technologies with higher efficiencies, it may likely come with environmental trade-offs over the life cycle of these nano-based technologies (Klöppfer et al. 2007; Franklin 2015; Guinée et al. 2017). Previous life cycle assessment (LCA) studies have assessed the impact of the use of nanomaterials in different solar technologies. Amorphous silicon (Kim and Fthenakis 2011; van der Meulen and Alsema 2011; Mohr et al. 2013), organic (Tsang et al. 2016), polymer (Roes et al. 2009), quantum dot (Şengül and Theis 2011), perovskite (Zhang et al. 2015), and single-walled carbon nanotube (Celik et al. 2017) photovoltaics are among the technologies assessed so far. In many of those studies, the solar technologies in which nanomaterials were embedded showed increased carbon emissions compared with those PV cells without nano-embedded technologies, mostly due to energy intensive processes for the production of nanomaterials—see meta-analysis (Pallas et al. 2018). Furthermore, two studies have assessed the environmental performance of gallium-indium-phosphide/multi-crystalline silicon (Meijer et al. 2003) and gallium-indium-phosphide/gallium-arsenide (Mohr et al. 2007) tandem modules. These are studies that use more than 10 to 15-year-old data for aggregated manufacturing processes for planar (not nanowires) III–V solar modules. In this study, we

assess the environmental performance of novel early-stage of development manufacturing routes of GaAs nanowire-based solar modules.

To evaluate the environmental performance of emerging technologies at an early stage of development, ex-ante (or prospective or anticipatory) LCA can be used (Roes and Patel 2011; Walser et al. 2011; Arvidsson et al. 2014; Wender et al. 2014; Villares et al. 2016, 2017). An LCA is ex-ante when a technology studied exists at an early stage of research and development (R&D)—i.e., at a lab or pilot scale—but is modeled for a projected future industrial/commercial-scale production (Arvidsson et al. 2017; Guinée et al. 2018). Thus, by applying ex-ante LCA at a new technology under development, unintentional future environmental impacts of this technology can be identified, and prevention actions can be developed (Cucurachi et al. 2018).

The objective of our study is to benchmark the commercialization of the GaAs/Si nanowire tandem solar cells against existing technologies. This is done by identifying the efficiencies and technical characteristics that need to be achieved in order for the technology to be successful. To that end, an ex-ante LCA was performed of up-scaled product systems for GaAs NW tandem solar cells on silicon (GaAs/Si) production, for two different manufacturing routes. Hotspots were identified in addition. As a starting point, lab-scale data of the different manufacturing routes have been used (Pallas et al. 2019).

Here, we first scale-up the lab-scale product systems for the two manufacturing routes and we perform an ex-ante LCA, including an impact assessment for a broad range of impact categories. Secondly, we compare the environmental performance of the two different manufacturing routes of the up-scaled GaAs/Si NW technologies to the existing commercial single-Si technology. Finally, we optimize the product systems, and we identify all the hotspots of concern and the conditions under which the new technology outperforms the incumbent technology. Ultimately, a benchmark for the successful commercialization of the new technology with minimum impact on the environment is presented. The results of our analysis can lead technology experts to further improve the technology towards industrialization.

2 Methodology

2.1 System description

The GaAs/Si solar cell consists of two sub-cells: the single-Si bottom cell and the GaAs nanowire top cell. The GaAs (III–V materials) nanowires are grown¹ in a process called epitaxy: either by a metal organic vapor phase epitaxy (MOVPE) or by

¹ Nanowire growth means the formation of the nanowire structure.

a metal organic chemical vapor deposition (MOCVD) process. These two processes are essentially the same process² (AZO Materials 2014). The GaAs NWs have a height of 1.5 μm , a diameter of 180 nm and grow in a temperature of about 650 °C (personal communication—IBM Research and Lund University).

For the production of the NW top cell, we model two different manufacturing routes which have been described in detail (Pallas et al. 2019). The first manufacturing route is the transfer route, in which the GaAs NWs grow on a GaAs (native) substrate by MOVPE, and then, they are peeled off and transferred to a silicon substrate (Wallentin et al. 2013; Anttu et al. 2014; Borgström et al. 2018). The second manufacturing route is the direct growth route, in which NWs grow directly on a silicon substrate by MOCVD, with the assistance of silicon dioxide (SiO_2) nanotubes that are developed on top of the silicon substrate (Borg et al. 2014; Schmid et al. 2015). Detailed information of the nanowire growth product systems is provided in the Supplementary material S1 and S2.

After NWs have grown and been placed on the single-Si wafer, the cell and module manufacturing processes follow. For the single-Si cell production, the module manufacturing, and the balance of system components required for the operation of the solar modules, well-established data exist in the literature (Jungbluth et al. 2012; Frischknecht et al. 2015). The product systems are shown in Fig. 1.

2.2 Scaled-up system description

Most processes in the product systems analyzed already exist at an industrial scale in the solar or the electronics industry. To up-scale the GaAs/Si nanowire tandem solar cells, we combine data from the lab measurements with data from industrial-scale processes found in the literature, data from the technology developers within the project, as well as their expert opinions with regard to up-scaling the lab processes and their related energy and material requirements.

Regarding the energy consumption of the system processes, values of already existing equivalent industrial processes have been used. In two cases, the energy consumption of proxy industrial processes from the silicon solar cell industry has been used in our baseline scenario. The two cases are the epitaxial process (MOVPE or MOCVD) for the growth of NWs (both routes) and the plasma-based dry etching processes (direct growth route). For the former, a large chemical vapor deposition (CVD) tool for silicon has been used as a proxy for up-scaling. For the latter, a dry etching tool for silicon has been used. These are based on discussions with the

technology experts within the NanoTandem consortium (EU H2020 - NanoTandem 2015).

Regarding the material consumption of the processes, combined data sources have been used. For those processes that already exist in an industrial setting, their specific material efficiencies have been used. For the wet etching and cleaning process steps, the material quantities required at the lab scale have been scaled proportionally to the average magnitude of wet etching and cleaning material requirements of the commercial wet etching processes in the silicon solar cell industry. For the dry etching processes in the direct growth route, the material quantities are not expected to differ compared with dry etching lab process values, and thus, the lab scale material quantities have been used (personal communication—IBM Research). Finally, the III–V material requirements of the epitaxial process, i.e., gallium and arsenic, have been calculated based on the expected up-scaled efficiency of the group III and group V metals (personal communication—Fraunhofer ISE). In particular, a backcasting approach has been used. The nanowire length (layer thickness), the dimensions, the III–V material composition, and the number of nanowires per wafer are known. The aimed output of the process is then combined with the expected efficiencies of the III–V materials (provided from the experts), and consequently, the input of III–V materials in the epitaxial process has been calculated. The remaining materials in the epitaxial processes have been up-scaled based on the best available technologies from several sources.

A detailed discussion regarding the up-scaling assumptions of each process is provided in the Supplementary material S3. An overview of the up-scaling of the two manufacturing routes is provided in the following sub-sections.

2.2.1 Transfer route up-scaling

In this route, there is a requirement of a native substrate for the growth of the III–V nanowires. The production of high pure III–V wafers is a complicated process, which requires significant amounts of materials and energy. In our analysis, we use a very detailed process inventory for the production of 625- μm -thick GaAs wafers from Smith (2018), including the production of polycrystalline GaAs boule, single-crystal GaAs boule, GaAs ingots, sawing the wafer with a diamond saw, pre-polishing and chemical mechanical polishing (CMP) of the wafer and cleaning, and finally quality control and packaging of the wafer. The aforementioned wafer thickness is essential in order to handle material losses during each CMP step and to achieve many substrate reuses (Woodhouse and Goodrich 2014). The inventory also includes the production of high purity gallium and arsenic, the synthetic diamond, the sawing slurry, and the CMP slurry. The detailed process data that have been collected are provided in the Supplementary material S6. An overview of the processes of the transfer route-specific processes for patterning the GaAs, the NW

² MOVPE and MOCVD are interchangeable in literature. The name MOVPE describes more specifically the underlying process.

Fig. 1 Production systems of **a** GaAs/Si NW tandem module (transfer route), **b** GaAs/Si NW tandem module (direct growth route), and **c** incumbent technology single-Si module. Different colors represent data

adopted from ecoinvent 3.4 (green color) and up-scaled lab processes for the two production routes (blue color). The detailed up-scaled lab system processes are provided in the Supplementary material [S1](#) and [S2](#)

growth and the epitaxial lift-off, as well as the up-scaling description are summarized in Table 1. A detailed discussion on the up-scaling is provided in the Supplementary material [S3](#). The detailed inventory with the up-scaled unit process data is provided in the Supplementary material [S4](#).

2.2.2 Direct growth route up-scaling

In this route, the GaAs NWs grow directly on a Si substrate. First, a SiO₂ layer is deposited on top of silicon and then SiO₂ nanotubes are developed to guide the growth of the NWs on

top of silicon. This manufacturing route contains many process steps as described in Supplementary material [S2](#). The specific direct growth route processes for the SiO₂ layer deposition, the patterning and SiO₂ nanotube formation and the growth of NWs, as well as the description of the up-scaling are summarized in Table 2. A discussion regarding the up-scaling assumptions for each process is provided in the Supplementary material [S3](#). The inventory with the up-scaled unit process data is provided in the Supplementary material [S5](#). Finally, the epitaxial processes in both routes require an input of trimethyl-gallium. The trimethyl-

Table 1 Transfer route processes and up-scaling description

Process—transfer route	(Proxy) technology for up-scaling	Source
Coating, drying, and optical lithography: coating the GaAs substrate with an organic resist and then photo-patterning the substrate	Coating, drying, and optical lithography: coating a copper substrate with an organic resist and then photo-patterning the substrate. This is the same process that is used for the development of a power electronic inverter.	Nordelöf 2018
Electroplating: plating gold on a GaAs substrate	Electroplating: plating gold on a nickel substrate	Nordelöf 2018
Wet etching: etch away the organic resist layer	Wet etching: energy from a wet etching tool for single-Si cells	Louwen et al. 2015
MOVPE or MOCVD (3 scenarios): deposition of III–V materials (nanowires)	Baseline: large CVD: energy from a CVD tool for deposition of silicon	Personal communication—Fraunhofer ISE
	Scenario 1: MOCVD: energy from an MOCVD tool for deposition of III–V materials (LED production (Veeco 2018))	Smith 2018
	Scenario 2: MOCVD: energy from an MOCVD tool for deposition of III–V materials (largest available tool for solar cells).	Personal communication—EU SiTaSol ¹
Epitaxial lift-off (ELO): peel-off III–V layer (nanowires). Then clean and re-polish the GaAs wafer for reuse	Epitaxial lift-off: peel-off III–V layer. Then clean and re-polish the GaAs wafer for reuse. Process used in multi-junction solar cells.	Smith 2018

¹ <https://sitasol.com/>

compounds production is provided in the Supporting material S7 with data from Smith (2018).

2.3 Life cycle assessment—goal and scope definition

Two ex-ante LCAs for the production of up-scaled GaAs/Si nanowire solar modules—one for each of the two different manufacturing routes—have been performed.

Thereupon, an LCA for the production of the commercial single-Si modules was performed. No optimizations have been assumed for the production of the incumbent single-Si modules. Any optimizations for single-Si modules would have also been applicable to the GaAs/Si modules, since the underlying single-Si technology is assumed to be the same.

Table 2 Direct growth route processes and up-scaling description

Process—direct growth route	(Proxy) technology for up-scaling	—
Low pressure chemical vapor deposition (LPCVD): deposition of SiO ₂	Chemical vapor deposition: energy from a CVD tool for deposition of silicon	Personal communication—Fraunhofer ISE
Coating, drying, and optical lithography: coating the GaAs substrate with an organic resist and then photo-patterning the substrate	Coating, drying, and optical lithography: coating a copper substrate with an organic resist and then photo-patterning the substrate. This is the same process that is used for the development of a power electronic inverter.	Nordelöf 2018
Reactive ion etching, O ₂ plasma, inductively coupled plasma (2 scenarios): plasma-based dry etching processes	Baseline: dry etching tool: energy from an atmospheric dry etching tool for silicon	Andersen et al. 2014
	Scenario 1: PECVD: energy from a plasma enhanced chemical vapor deposition (PECVD) tool for silicon	Louwen et al. 2015
Acid-based cleaning, HF etching, acetone and IPA, TMAH etching: wet etching processes	Wet etching: energy from a wet etching/cleaning tool for single-Si cells	Louwen et al. 2015
MOVPE or MOCVD (3 scenarios): deposition of III–V materials (nanowires)	Baseline: large CVD: energy from a CVD tool for deposition of silicon	Personal communication—Fraunhofer ISE
	Scenario 1: MOCVD: energy from an MOCVD tool for deposition of III–V materials (LED production (Veeco 2018))	Smith 2018
	Scenario 2: MOCVD: energy from an MOCVD tool for deposition of III–V materials (largest available tool for solar cells)	Personal communication—EU SiTaSol

The life cycle environmental impact of the GaAs/Si modules is compared with that of the reference single-Si modules. A number of optimization scenarios are explored for the GaAs/Si module to reduce its environmental impact. The functional unit used is 1 kWh of electricity production, with the GaAs/Si NW modules and the single-Si module as the alternatives compared. The geographical scope of the study is assumed to be Southern Europe, which is also representative for the global average insolation, resulting in an insolation of 1700 kWh/(m² year) (Frischknecht et al. 2015). The system boundaries for the GaAs/Si NW modules include the raw material extraction, the GaAs and single-Si wafer manufacturing, the growth of NWs, the single-Si cell and module manufacturing, and the operation of the PV system. The system boundaries for the single-Si module include the raw material extraction, the single-Si wafer production, the single-Si cell and module manufacturing, and the operation of the PV system. The solar modules are assumed to operate on slanted-roofs. The inverter and balance of system (BOS) components for slanted-roof mounted applications have been taken into account. End-of-life treatment has not been taken into account due to the lack of solar technologies recycling data, as well as due to the lack of nano-specific emission data. The product systems, reference flows, and system boundaries are shown in Fig. 1.

2.4 Data

For the GaAs NW top cell manufacturing, in the GaAs/Si tandem formation, a combination of data from the literature, the ecoinvent 3.4 database (Wernet et al. 2016), and the NanoTandem project technology partners (EU H2020 - NanoTandem 2015) has been used. For the single-Si bottom cell of the GaAs/Si tandem formation, the module manufacturing, and the BOS components, for slanted-roof installations, data from the ecoinvent database have been used. Finally, for the incumbent single-Si module technology, for the single-Si wafer, cell, module, and BOS for slanted roof installations, data from the ecoinvent database have been used. In order to contribute to the reproducibility and transparency of results (Hertwich et al. 2018), detailed inventory data as well as ecoinvent 3.4 process names and calculations are provided in the Supplementary material S4 to S7.

2.5 Life cycle impact assessment

For the life cycle impact assessment (LCIA), the CML 2001 impact assessment method is used (Guinée et al. 2002). The impact categories that have been assessed are the following: climate change, land use, acidification, ozone depletion, freshwater, marine, terrestrial ecotoxicity, eutrophication, human toxicity, and photochemical oxidation. The cumulative primary energy demand (CED) has also been assessed. It represents

the direct and indirect primary life cycle energy requirements for the production of the different solar technologies. It is the total amount of all the renewable and non-renewable energy inputs (Mohr et al. 2013). The software that has been used in our analysis is the CMLCA 6.0 version (www.cmlca.eu). Furthermore, the latest product environmental footprint (PEF) impact assessment method has also been used. Results are discussed in Sect. 3.1 and included in the Supplementary material S9.

2.6 Additional parameters

2.6.1 Insolation, performance ratio, lifetime, and conversion efficiency

As discussed above, the functional unit that has been selected in the study is 1 kWh of electricity production from the different solar technologies. In order to calculate the solar module area³ that is required per kWh of electricity production, additional parameters are required. These parameters are the insolation, performance ratio (PR) of the module, lifetime, and conversion efficiency of the module (Monteiro Lunardi et al. 2017). The insolation is assumed to be 1700 kWh/(m² year) (Frischknecht et al. 2015). The performance ratio of today's modules is assumed to be about 85% (Fraunhofer ISE 2017). The lifetime of the modules is assumed to be 30 years (Fthenakis et al. 2011). Lastly, the conversion efficiency of the single-Si modules has been assumed to be 18%. The average stabilized efficiency for single-Si solar cells in mass production is about 20% (ITRPV Working Group 2017; ITRPV 2018). For module efficiency, we assume a constant 2% point cell to module loss (Louwen et al. 2015). The goal of the NanoTandem project is to develop a GaAs/Si NW solar cell with an efficiency beyond 25%. For the up-scaled GaAs/Si NW modules, an 28% module efficiency is assumed (personal communication—SOL Voltaics). For the calculation of the module area per kWh of electricity production, the method described in Monteiro Lunardi et al. (2017) has been used. Calculations are provided in the Supplementary material S8. The parameters and values are summarized in Table 3.

2.6.2 Energy payback time

The energy payback time (EPBT) is an important metric that is applied in the solar technologies. It calculates the time (usually in years) that is required for a solar technology to operate in order to generate the amount of energy that has been invested for its production (Celik et al. 2018). To calculate the EPBT, the CED is used together with other parameters:

³ The solar module area is essentially the size of the solar module to produce 1 kWh of electricity. It is dependent to the insolation, conversion efficiency, performance ratio, and lifetime of the module.

Table 3 Overview of all parameters for the baseline scenario for the different solar technologies

Parameter	Single-Si module	GaAs/Si module—transfer route	GaAs/Si module—direct growth route
Conversion efficiency	18%	28%	28%
Insolation	1700 kWh/(m ² year)	1700 kWh/(m ² year)	1700 kWh/(m ² year)
Performance ratio (PR)	85%	85%	85%
Lifetime	30 years	30 years	30 years
Epitaxial tool	—	CVD proxy	CVD proxy
GaAs wafer reuse	—	100 times	—
Gold losses	—	No recovery	—
Dry etching	—	—	Dry etching of Si proxy

the insolation, performance ratio, conversion efficiency of the module, conversion factor from MJ (primary energy) to kWh, and the average conversion efficiency from energy to electricity for the European electricity grid (Bhandari et al. 2015; Celik et al. 2016)—Supplementary material S8.

2.6.3 Balance of system components and inverter

The BOS components and the inverter have been included in our analysis. These data are provided from the ecoinvent database for the production of a 3-kWp (kilowatt-peak) slanted-roof installation PV system. The BOS components, which include among others the structural components to mount the PV modules on the roofs, scale proportionally to the area of the solar module (Bobela et al. 2017). Since the tandem module is assumed to have a higher conversion efficiency compared with the single-Si module, it will result in less module area requirements for the production of 1 kWh of electricity, and thus, it will result in less BOS components per kWh when compared with a single-Si module. On the other hand, the inverter scales proportionally to the electric power of the module (Bobela et al. 2017). Since the inverter input is power related, both the GaAs/Si NW modules and the single-Si module will require the same amount of inverter for 1 kWh of electricity production. The material and energy requirements of the BOS components and the inverter have been calculated and explained in the Supplementary material S8.

2.7 Scenarios

The baseline scenario includes the up-scaled processes as described in Tables 1 and 2. In the baseline scenario, the efficiency of the tandem modules is assumed to be 28% and a large CVD tool for silicon is used as a proxy for the epitaxial (MOVPE) process in both routes. Furthermore, the GaAs wafer is assumed to be reused 100 times (for the transfer route), and a dry etching process is used as a proxy for the RIE, O₂

plasma, and ICP processes (for the direct growth route, Table 3).

In addition to the baseline scenario, additional process-specific scenarios are applied to the sensitive MOVPE processes (in both routes) and to the RIE, O₂ plasma, and ICP (in the direct growth route). Furthermore, a number of scenarios are explored for further optimization of the tandem technology.

2.8 Reuse of GaAs wafer (transfer route)

III–V/Si NW solar cells are quite expensive at the moment due to their early stage of development. Successful commercialization of the technology implies a high reuse rate of the wafer. Five to 10 wafer reuses have already been achieved (Adams et al. 2012; Lee et al. 2012). However, as a baseline case, we assume 100 times reuse of the GaAs wafer. This is considered necessary in order to reduce costs and achieve a cost-competitive technology (Ward et al. 2016; Essig et al. 2017). In addition, a maximum of 500 reuses is also modeled as this can significantly reduce the production costs even further (Woodhouse and Goodrich 2014). We recall that a thick GaAs wafer—like the one we modeled in this study of 625-μm thickness—is necessary in order to achieve a large number of reuses (Woodhouse and Goodrich 2014).

2.9 Chemical mechanical polishing (transfer route)

The epitaxial lift-off (ELO) process is used to transfer the GaAs NWs on a silicon wafer. In each ELO step, a CMP step also takes place to re-polish the GaAs wafer in order to be ready for reuse. CMP is also considered a very expensive process, and for that reason, one CMP step follows for each 10 ELO steps in this optimization scenario (Ward et al. 2016; Essig et al. 2017; Abdul et al. 2018).

2.10 Gold recovery (transfer route)

Gold is a strong light absorber, and thus, the gold particles are peeled off after they have been used for the growth of NWs. In our previous study, we identified the use of gold as an important driver for various impact categories (Pallas et al. 2019). In addition, gold use increases the cost of the tandem module (Jafari Jam et al. 2014). Although the use of gold is minimized by the use of the electroplating process (Pallas et al. 2019), a theoretical scenario of 90% recovery of gold (Shen and Xue 2007; Pati et al. 2016) to be used in the same system is modeled for the peeled-off gold particles.

2.11 Trifluoromethane (CHF₃) (direct growth route)

The use of CHF₃ has been identified in our previous study as an important driver of ozone depletion impacts (Pallas et al. 2019). The reduction on CHF₃ use that is required to be realized, in order for the ozone depletion impact of the GaAs/Si module to breakeven to that of the incumbent technology, will be calculated.

3 Results

3.1 Life cycle impact assessment—baseline scenario

As mentioned in the previous chapter, we performed an ex-ante LCA of the emerging GaAs/Si NW modules for two different manufacturing routes and compared the impact assessment results with the incumbent single-Si module technology. The characterization results for the baseline scenario, for 10 impact categories, are presented in Table 4.

Table 4 shows that the GaAs/Si NW modules, for both routes, perform better compared with the incumbent technology in all impact categories with one exception. That is with the exception of the ozone depletion impact, which is much higher in the direct growth route. This is caused by the use of CHF₃ in the reactive ion etching process. For all other impact categories assessed, the direct growth route performs best. For instance, the impact related to climate change is about 29% lower for the direct growth route and 23% lower for the transfer route GaAs/Si modules compared with the single-Si modules for the baseline scenario. For the other impact categories, the direct growth route performs between 20 and 30% better compared with the incumbent technology (with the already-mentioned exception of the ozone depletion), while the transfer route performs 5 to 24% better compared with the single-Si solar modules.

More specifically, within the nano-embedded solar technology in the transfer route, the eutrophication and terrestrial ecotoxicity impacts are 5% and 9% better compared with the incumbent technology. This difference is not that high and can

be considered comparable with the impact of the single-Si module for these two impact categories. The additional impact comes from the GaAs wafer production and the requirement of gold from the electroplating process in this route. The direct growth route has thus the best overall environmental performance, due to the GaAs substrate-free and gold-free growth of NWs as opposed to the transfer route. The detailed contribution analysis is presented in Sect. 3.3. Finally, the characterization results have also been calculated with the latest PEF impact assessment method. The percentage advantage of the environmental impacts of the tandem technologies compared with the incumbent is similar to that of the CML 2001 method, as presented in Table 4. Results are provided in the Supplementary material S9.

3.2 Energy payback time

For the baseline scenario, the EPBT of the GaAs/Si nanowire tandem modules are 1.37 and 1.56 years for the direct growth route and the transfer route, respectively. The EPBT for the incumbent single-Si module is 1.84 years. Thus, the GaAs/Si technology results in a smaller EPBT compared with the incumbent technology, for both manufacturing routes.

3.3 Contribution analysis—baseline scenario

Figure 2 shows the contribution of the processes to all impact categories assessed for the transfer route. We can notice that, for most impact categories assessed, about 80 to 90% of the impact is due to the single-Si wafer, cell, module, inverter, and BOS components, and the remaining impact is due to the NW-specific processes. In particular, the single-Si wafer is the main driver for acidification (29% of the total impact), climate change (45%), land use (35%), and CED (44%). The single-Si cell manufacturing is the largest contributor of ozone depletion (38% of the total impact). The inverter is the main contributor for the eutrophication (33%), human toxicity (42%), photochemical oxidation (33%), and terrestrial ecotoxicity (40%) impact categories. The BOS components are the main driver of freshwater ecotoxicity (54%) and marine ecotoxicity (37%) impacts. Lastly, it is worth noting that the GaAs wafer production and the electroplating process for the gold deposition (within the patterning and gold deposition step in the graph) also show a considerable contribution to some impact categories. For instance, the contribution of the GaAs wafer production to ozone depletion, terrestrial ecotoxicity, and CED (even after the 100 times reuse that is considered in the baseline scenario) is about 11–12%. The contribution of the electroplating process to eutrophication is about 10%, which is due to a very small amount of gold that is required (169 mg/m²). The impact of the production of gold and the related metals that are present in the sulfidic tailings of the gold production activity is a well-known problem of environmental

Table 4 Characterization results and overview of the baseline scenario parameters for 1 kWh of electricity production by the commercial single-Si module and the prospective GaAs/Si modules

	Incumbent: single-Si module	Transfer route: GaAs/Si nanowire module	Direct growth route: GaAs/Si nanowire module
Baseline scenario parameters overview—benchmarking	Efficiency: 18% Insolation: 1700 kWh/(m ² year) PR: 85%	Efficiency: 28% Insolation: 1700 kWh/(m ² year) PR: 85% MOVPE: CVD proxy Wafer reuse: 100 times Gold: no recovery CMP: in each ELO step	Efficiency: 28% Insolation: 1700 kWh/(m ² year) PR: 85% MOVPE: CVD proxy Dry etching: atmospheric
Impact categories	Characterization results (improvement compared with incumbent %)		Unit
Climate change	4.84E−02	3.74E−02 (23%)	3.45E−02 (29%) kg CO ₂ -eq
Acidification	3.06E−04	2.47E−04 (19%)	2.30E−04 (25%) kg SO ₂ -eq
Eutrophication	1.57E−04	1.49E−04 (5%)	1.23E−04 (22%) kg PO ₄ -eq
Land use	2.60E−03	2.21E−03 (15%)	1.97E−03 (24%) m ² a
Ozone depletion	4.06E−09	3.23E−09 (20%)	8.51E−08 (−2000%) kg CFC-11-eq
Terrestrial ecotoxicity	3.05E−04	2.78E−04 (9%)	2.43E−04 (20%) kg 1,4-DCB-eq
Marine ecotoxicity	2.07E+02	1.67E+02 (19%)	1.55E+02 (25%) kg 1,4-DCB-eq
Freshwater ecotoxicity	1.03E−01	7.84E−02 (24%)	7.20E−02 (30%) kg 1,4-DCB-eq
Human toxicity	1.13E−01	9.53E−02 (16%)	8.83E−02 (22%) kg 1,4-DCB-eq
Photochemical oxidation	1.60E−05	1.28E−05 (20%)	1.23E−05 (23%) kg ethylene-eq

pollution and human health issues in several countries with gold mining activity (Aitio et al. 2015; Fashola et al. 2016; Nakazawa et al. 2016; Tejeda-Benitez et al. 2016; Akpalu and Normanyo 2017). The use of gold and the GaAs wafer are unique for the transfer manufacturing route—Supplementary material S9.

Moreover, Fig. 2 shows that the BOS and inverter have a significant contribution to (eco)toxicity impacts. For the inverter production, the upstream processes “treatment of sulfidic tailings from copper production” and “primary copper production” are the main contributors to eutrophication, human toxicity, and terrestrial ecotoxicity. For photochemical

oxidation, the biggest contributor is the production of capacitors and auxiliaries that are also inputs for the inverter production. For the BOS components, the treatment of scrap copper in a municipal incineration is the main contributor of freshwater ecotoxicity, while for marine ecotoxicity, the biggest contributor is the anode production followed scrap copper treatment. Furthermore, the single-Si cell production requires an input of trichloromethane (CHCl₃) and chlorodifluoromethane (CHClF₂), which notably increase the ozone depletion impact. Lastly, the hard coal mine operation and preparation, for the production of electricity, are the biggest contributors of acidification and climate change impacts in the single-Si wafer

Fig. 2 Results of the contribution analysis for the transfer route. Detailed results for the processes within the “patterning and gold particle deposition” step presented in the graph are provided in the Supplementary material S9

production process, while the hardwood forestry is the largest contributor for land use.

In the direct growth route, the contribution analysis showed similar results for the major drivers in each impact category as in the transfer route (Fig. 3). We can notice in Fig. 3 that, for most impact categories, about 90 to 95% of the impact is due to the single-Si wafer, cell, module, inverter, and BOS components (with the exception of the ozone depletion), and the remaining impact is due to the NW-specific processes—see Supplementary material S9. The only difference is in the ozone depletion results, for which the main contributors are the reactive ion etching processes in the SiO₂ nanotube formation step due to the use of CHF₃.

In particular, CHF₃ is produced during the fluorination of CHCl₃ which emits tetrachloromethane (CCl₄) to air, a strong ozone depleting gas (Liang et al. 2017; Pallas et al. 2019). Although CCl₄ is a fully controlled substance, emissions are not decreasing fast enough due to various potential sources (Fraser et al. 2014; Lunt et al. 2018; Sherry et al. 2018). Production of CHF₃ and hydrofluorocarbons has been identified as sources of ozone-depleting gas emissions (Montzka et al. 2011; Han et al. 2012; Liang et al. 2017; Sherry et al. 2018).

3.4 Environmental impact under different scenarios

In the baseline scenario, for both routes, we have considered a CVD tool for silicon as a proxy for up-scaling the MOVPE process. This tool can handle about 7200 × 8-in. wafers per hour. Furthermore, we assumed that a dry etching tool for silicon is used as a proxy for up-scaling the RIE, O₂ plasma, and ICP process of the direct growth route. To analyze the effects of changes in the energy inputs of the assumed up-scaled processes to the impact assessment results, we performed a scenario analysis, including a worst-case scenario.

In particular, the energy consumption of two additional tools is modeled for the MOVPE process in both routes. First, the energy consumption of a proxy MOCVD tool for III–V material deposition for LED production has been modeled (this tool can handle 124 × 4-in. wafers per run). Secondly, the energy consumption of a current MOCVD tool for III–V material deposition for solar cell production has been modeled (worst-case scenario—this tool can handle 37 × 4-in. wafers per run).

In addition, for the direct growth route, the energy consumption of a proxy PECVD tool has been modeled for the plasma-based etching processes RIE, O₂ plasma, and ICP (worst-case scenario). Table 5 summarizes the energy input values of the different tools. Additional information is provided in the Supplementary material S3. The results of the scenario analysis are shown in Fig. 4.

Figure 4 shows the results under the different scenarios for two selected impact categories (results for all impact categories are provided in the Supplementary material S10). The results show that the climate change impact of the GaAs/Si NW module is lower compared with the single-Si module, in all scenarios assessed, for both manufacturing routes. In particular, even in the worst-case scenario, in which the energy parameter of the epitaxial process is increased from 0.68 kWh/m² (baseline scenario) to 213 kWh/m² (scenario 2: worst-case scenario), the tandem technology performs better/comparable with the incumbent. For eutrophication, the GaAs/Si module performs worse/comparable with the incumbent, in the worst-case scenario, for the transfer route only. The reason is that the eutrophication impact in the transfer route is already at the same level as the incumbent in the baseline scenario, due to the use of gold. However, the eutrophication impact of the direct growth route is still better/comparable with the incumbent even in the worst-case scenario.

Fig. 3 Contribution analysis for the direct growth route. The detailed results for the processes within the “patterning and SiO₂ nanotube formation” step presented in the graph are provided in the Supplementary material S9

Table 5 Overview of energy input values of the different proxy technologies examined in the scenario analysis

Process	Baseline scenario	Scenario 1 (both routes)	Scenario 2 (both routes)	Scenario 3 (direct growth route only)
MOVPE—both routes	CVD-Si proxy: 0.68 kWh/m ²	MOCVD-Led proxy: 30 kWh/m ²	MOCVD-Solar: 213 kWh/m ² (worst case)	—
RIE 1, O ₂ plasma, ICP (3 consecutive processes)—direct growth route	Dry-etching Si proxy 5.34 kWh/m ²	—	—	Plasma (PECVD) proxy: 22.8 kWh/m ² (worst case)
RIE 2—direct growth route	Dry-etching Si proxy: 1.78 kWh/m ²	—	—	Plasma (PECVD) proxy: 3.4 kWh/m ² (worst case)

Finally, for the additional scenario in the direct growth route, in which a plasma-based process is modeled as a proxy for the dry etching processes, there is only a minor increase for all impact categories.

In general, for most impact categories assessed, the two nano-embedded technologies perform better or comparable with the incumbent technology, even in the worst-case scenario in which the energy of a current energy-intensive III–V MOCVD tool for solar cells is modeled. That is true only if the assumptions for the different parameters, as presented in Table 3, are realized. The only exception is the category of land use impacts in the worst-case scenario, in which the single-Si module performs better than both nano-based routes, due to the additional land required for the increased electricity requirements. Lastly, for the direct growth route, the EPBT is 1.9 years when the worst-case scenarios are applied (scenarios 2 and 3). The result can be considered comparable with the EPBT of 1.84 years of the single-Si module.

3.5 Impact reduction scenarios for further optimization of the transfer route—benchmarking

The nano-embedded technology performs better or at least comparable in most impact categories in all scenarios.

However, with the application of various impact reduction scenarios, we can achieve even better performances for the up-scaled GaAs/Si tandem technologies. The results of the application of the different scenarios (Sect. 2.7) for the transfer route are presented in Fig. 5.

3.6 Transfer route

3.6.1 Recycling of gold

As already discussed, there is the requirement of the deposition of gold particles through the electroplating process in the transfer route. The role of the gold particles is to assist the growth of NWs in the MOVPE reactor. However, the gold particles will not be part of the solar cell, and thus, they are peeled off and disposed. The amount of gold required per m² of module is very small—i.e., 1.69E−4 kg/m² or 169 mg/m². Even though the quantity required is very small, it has a considerable impact on eutrophication, human toxicity, and marine toxicity impacts (as we showed earlier in Fig. 2). In this scenario, we have assumed a 90% recovery of the gold. This assumption reduces the eutrophication impact by 9.4%, the marine ecotoxicity impact by 6%, and the human toxicity impact by 5% (Fig. 5).

Fig. 4 Climate change and eutrophication impact results under the different scenarios for the transfer and the direct growth route. The vertical dashed blue line shows the single-Si module impact

3.6.2 Reuse of GaAs substrate

It is assumed in the baseline scenario that the wafer is reused 100 times. We have also modeled the case in which the wafer is reused 500 times. This might be necessary for the cost-competitive commercialization of the technology, as described in Sect. 2. Terrestrial ecotoxicity is improved by 9.3% compared with the baseline scenario, followed by ozone depletion (9%), CED (9%), land use (7.2%), and climate change (6.7%), followed by smaller improvements for the other impact categories (Fig. 5). We should also notice that further reuse of the wafer (above 500 times) does not offer any further considerable improvement in the overall impact (Supplementary material S11).

3.6.3 Chemical mechanical polishing every 10 steps

The CMP step is an essential step of the ELO process, in which the GaAs substrate is cleaned and re-polished in order to be reused. Technological improvement can potentially offer one CMP step for each 10 ELO steps, as described in Sect. 2. This does not result in a considerable change. Minor improvements can be found for the land use impact (3.6%), followed by CED (2.7%) and eutrophication (2.2%) (Fig. 5).

Lastly, Fig. 5 shows that the biggest cumulative improvement can be achieved for eutrophication (about 17%) followed by CED, land use, ozone depletion, and terrestrial ecotoxicity (about 12%). Climate change improves about 9% when all three impact reduction scenarios achieved.

3.6.4 Direct growth route

We recall that the direct growth route of the GaAs/Si module performs better compared with the single-Si module in all impact categories assessed but one, ozone

depletion. In order for the new technology to breakeven with a single-Si technology, the use of the CHF_3 by the reactive ion etching processes needs to be reduced by more than 98%. This essentially means that the use of CHF_3 needs to be eliminated or at least minimized, if the direct growth route is to be superior in all impact categories assessed. Lastly, if all optimizations are achieved, then the two manufacturing routes—the transfer and direct growth route—breakeven in most impact categories.

4 Discussion

4.1 Overall performance throughout the life cycle

In this study, we performed an ex-ante LCA for the production of the emerging GaAs/Si tandem nanowire modules for two different production routes—the transfer and direct growth route—and we compared the environmental performance of the emerging nano-embedded solar technology with the commercial single-Si technology. For the baseline scenario and if all the parameter assumptions are realized, both manufacturing routes perform better compared with the incumbent single-Si technology and result in a lower EPBT. For the direct growth route, more than 90% of the impact is due to the single-Si wafer, cell, module, inverter, and BOS manufacturing, and less than 10% is due to SiO_2 template formation and the NW growth (Fig. 3). This additional 10% burden of the NW production is compensated by the higher efficiency that the GaAs/Si module can achieve. Similarly, for the transfer route, about 80% of the impact is due to the module and operation components and about 20% is due to the GaAs substrate, gold particle deposition, and the NW growth (Fig. 2). Again, this additional 20% burden of the nano-embedded

Fig. 5 Percentage contribution improvement under different optimization scenarios of the transfer route. See the Supplementary material S10 for more details

technology is compensated by the higher efficiency that the GaAs/Si module can achieve.

4.2 Area-related and power-related components

In the results presented in the contribution analysis earlier (Figs. 2 and 3), it is shown that the single-Si wafer is the largest driver for acidification, climate change, land use, and CED, and the balance of system components are the largest drivers of marine and freshwater ecotoxicity. Since the GaAs/Si nanowire tandem technology uses a single-Si wafer as a bottom cell, the higher efficiency the tandem technology can achieve compared with the single-Si technologies, the less wafer area it will require per kWh of electricity production. Furthermore, the BOS components are also area-related components. Again, the higher efficiency that the tandem technology can achieve compared with the incumbent, the less BOS components installation will be required per kWh of electricity production. This relationship between area-related components and efficiency leads to reductions in the aforementioned impacts for the tandem technology. The savings that are achieved in the impacts of the area-related components provide room to the tandem technology to compensate for the additional impacts of the NW growth.

Finally, the inverter is a power-related component of the PV system. Since the functional unit selected is 1 kWh of electricity production, all alternatives compared will have the same inverter amount as input. The inverter is the biggest contributor of eutrophication, human toxicity, photochemical oxidation, and terrestrial ecotoxicity.

4.3 Hotspots of concern

Gold and CHF_3 are important contributors to the overall impact of the up-scaled nano-embedded technology. This is in line with the results of the LCA of the NW-based technology at the lab scale (Pallas et al. 2019). In the case of CHF_3 , we showed that minimization of the material is required to improve the ozone depletion impact of the direct growth route, for instance by exploring fluorine-free etching materials (Abdolahad et al. 2010). Finally, the impact of the GaAs wafer is quite significant for some impact categories, even after 100 times of reuse in the baseline scenario. A maximum of 500 reuses was modeled, and we showed that after 500 reuses there is no significant impact reduction anymore.

4.4 Scenario analysis

The scenario analysis showed that, even in the worst-case scenario, the GaAs/Si module performs better or comparable with commercial single-Si modules. Furthermore, the III–V solar technology can gain from synergies from the fast development of other technologies, like the LED production. We

showed that a new MOCVD tool for III–V material deposition for LED production can handle 124 wafers per run while the MOCVD tool for solar technologies can handle 37 wafers per run.

For the baseline scenario, we have modeled the energy of a large CVD tool for silicon and used that as a proxy for up-scaling. This tool can handle 7200×8 -in. wafers per hour. Although such a large tool has not been commercialized yet for III–V materials, there is a new high-throughput and high-yielding process from SOL Voltaics, called Aerotaxy (Heurlin et al. 2012; Borgström et al. 2018; SolVoltaics 2018) that can soon offer cost-competitive GaAs/Si NW tandem solar cells. In particular, III–V epitaxial tools can have a deposition rate close to $60 \mu\text{m/h}$ in the short term (Essig et al. 2017), while the large CVD tool for silicon that we modeled in our baseline scenario has a deposition rate of $3\text{--}10 \mu\text{m/min}$ (personal communication—Fraunhofer ISE). The new Aerotaxy process, however, can offer a deposition rate of $1 \mu\text{m/s}$ or $60 \mu\text{m/min}$ (Yang et al. 2015; Barrigon et al. 2017), which offers a very high throughput even compared with commercial CVD tools for silicon. Due to this high throughput, the Aerotaxy process is likely to offer a similar performance to existing silicon deposition tools. Thus, the selection of a large CVD tool for silicon in the baseline scenario as a proxy for up-scaling the epitaxial process can be considered realistic, when we take these recent developments into account.

4.5 Toxicity data

Nano-specific toxicity has not been considered in this study due to the lack of characterization factors. In a previous study, we have shown that studies on LCA of nanotechnologies, for various sectors of the economy, also do not consider nano-specific emissions due to lack of relevant data (Pallas et al. 2018). Toxicity of nanomaterials can be affected by many factors (for example, different shapes and dimensions of nanowires can have a significant effect on the toxicity of the materials), and nanotoxicity is still an emerging field of research. In the case of the nanowire-based solar cells, nanowires will be well bonded into the silicon substrate and will also be encapsulated within glass in the module. Thus, emissions of nanomaterials should be considered only at the end of life of the solar technology (which is out of the scope of this study). Since the underlying technology of the nanowire-based solar module and the single-Si module is the same, the only difference between the two technologies compared is the nanowire layer. Successful treatment of the nano-layer at the end of life of the technology, by etching and recovering/treatment of the nanomaterials to eliminate emissions, will be of high importance.

5 Conclusions

This ex-ante LCA study can be also seen as a benchmark LCA for the improvements that need to be achieved for the emerging technology to perform better compared with the incumbent. Our benchmark is thus a 28% efficient GaAs/Si nanowire tandem module and at least 100 times GaAs substrate reuses for the transfer route. The incumbent technology is an 18% efficient single-Si module (that is a 10% efficiency difference between the emerging technology and the incumbent). The insolation is assumed to be 1700 kWh/(m² year), and a performance ratio of 85% is applied to all technologies assessed.

Either under these conditions only or as a minimum, even in the worst-case scenario in which the energy consumption of a current epitaxial tool is modeled, the GaAs/Si modules perform better or comparable with single-Si modules for most impact categories assessed, as we showed in Sect. 4.4. Furthermore, in the baseline scenario in which we modeled the energy consumption of a CVD tool for silicon, the transfer route performs 5 to 24% better and the direct growth route performs 20 to 30% better compared with single-Si modules (except for ozone depletion).

Our results show that the direct growth route has the best potential for up-scaling, mainly due to the III–V substrate-free and gold-free growth. The use of CHF₃ however needs to be minimized if the direct growth route is going to offer a superior performance in all impact categories. On the other hand, for the transfer route, *if* technological innovations take place, the III–V substrate can be reused by about 500 times, the use of gold is minimized, and one CMP step is considered for each 10 ELO steps, *then* the transfer route can offer a similar performance to the direct growth route. Finally, the energy consumption of the epitaxial process is of high importance for a successful commercialization of the emerging technology. Improvements in the solar cell industry are expected, as well as benefits from improvements in other sectors, like the electronics sector for LED production. Lastly, the Aerotaxy process, that we described earlier, can offer a high-throughput process and an unprecedented rate of nanowire growth, potentially resulting in a similar or better performance to existing large silicon deposition tools.

The limitation of this study is the non-inclusion of the end-of-life treatment in the analysis, specifically the non-inclusion of nano-specific emissions due to the lack of relevant data. The treatment of nanowaste at the end of life of the technology and the potential recovery/treatment of nanomaterials to avoid emissions can be of high importance.

Last but not least, it is noted that all above conclusions are “if-then” conclusions. Only if the assumptions we made appear to be valid or are realized, then the conclusions as drawn above are valid. The conclusions are thus

scenario-based conclusions and not yet performance-based conclusions. The LCA results of this study can only be used as a benchmark indicating the improvements needed for the emerging technology to eventually perform better compared with the incumbent technology. Finally, in addition to the environmental performance benchmark that was explored in this study, significant improvements in the cost of the production of the emerging technology need to be realized before the technology can become commercial.

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Compliance with ethical standards

Conflict of interest The authors declare that they have no conflict of interest.

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